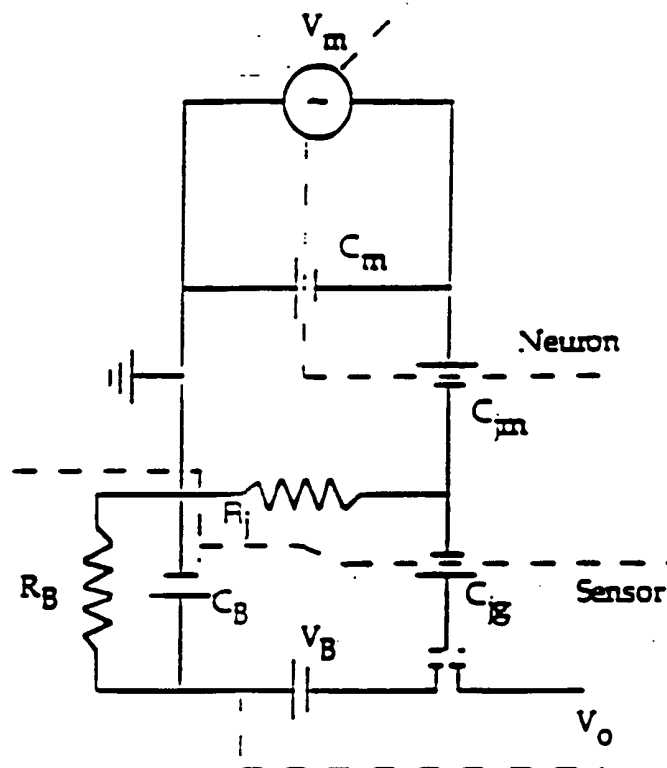


Fig. 1



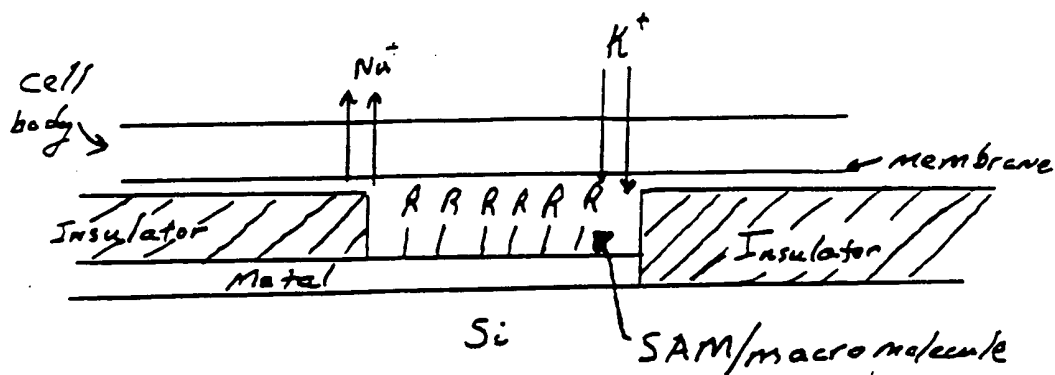


Fig. 2A

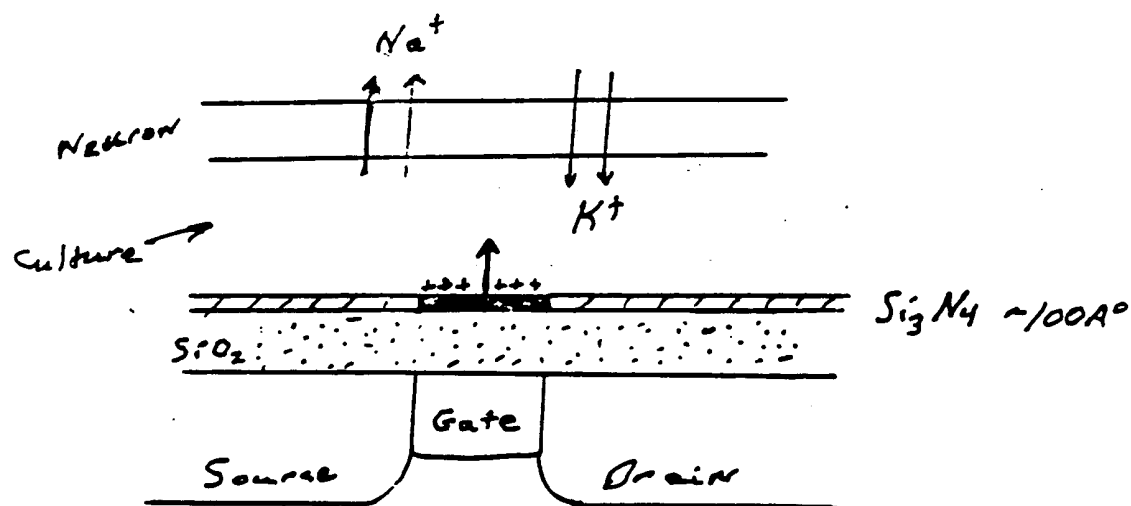
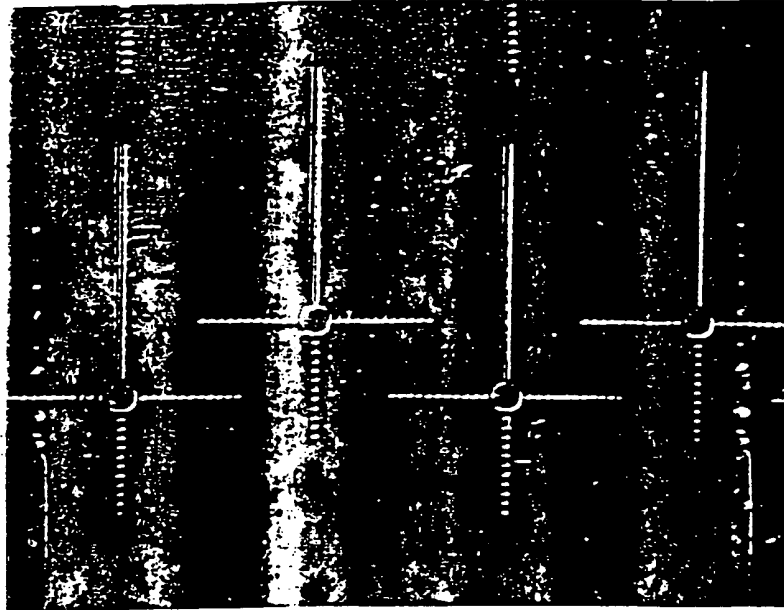


Fig. 2B

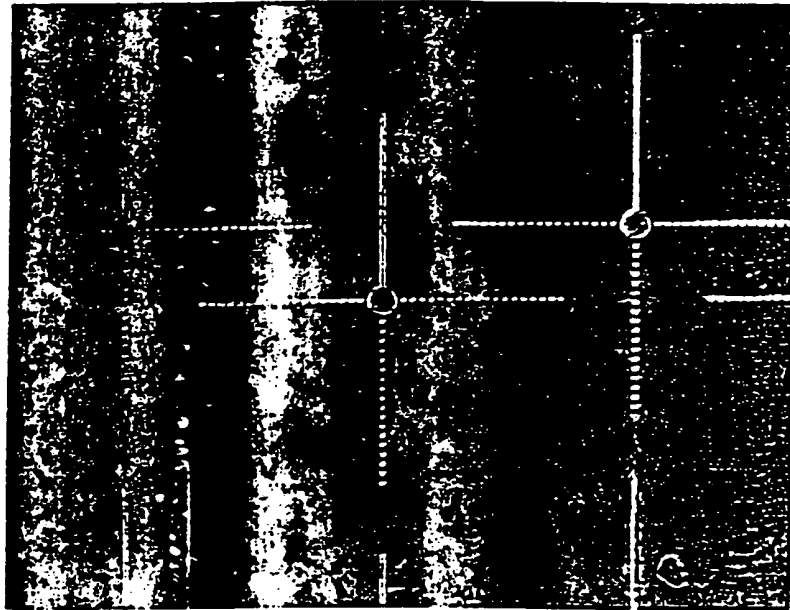
TOP SECRET 000000

FOI 90-8270660



Patt062196: DS100194 Mask, Region 3. Metallized pattern on glass, 4 J/cm² dcse. 10x objective.

Figure 3A

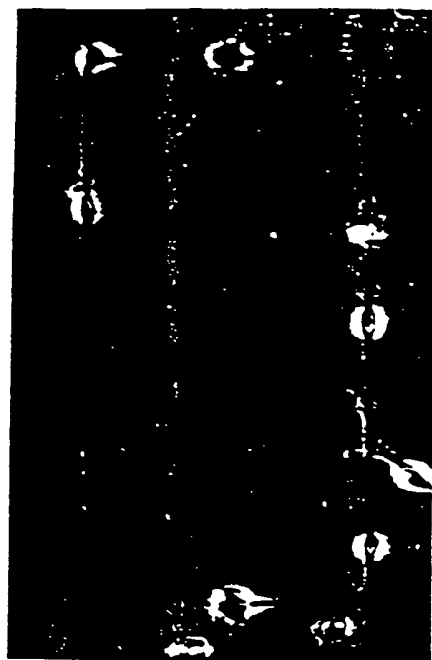
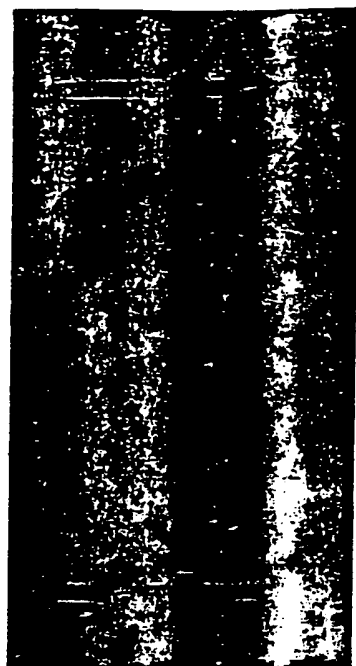


Patt062196: DS100194 Mask, Region 4. Metallized pattern
on silicon, 4 J/cm² dose. 10x objective.

Figure 3B

00000194-00000000

(a)



(b)



Figure 4. Photographs of the (a) RT12 mask feature and the patterned day 2 *in vitro* hippocampal neurons: (b) RT6 mask feature and the patterned day 2 *in vitro* hippocampal neurons.

FOI 50-820550